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RESPONSE UNDER 37 C.F.R. § 1.116 EXPEDITED PROCEDURE EXAMINING GROUP 1278

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Cyril Cabral, Jr., et al.

Examiner:

Long Pham

Serial No:

10/662,900

Art Unit:

2814

Filed:

September 15, 2003

Docket:

YOR920030218US1(16714)

For: REDUCTION OF SILICIDE FORMATION TEMPERATURE ON

SiGe CONTAINING SUBSTRATES

Confirmation No: 1278

Dated:

December 21, 2006

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

RESPONSE UNDER 37 C.F.R. § 1.116

Sir:

In response to the Office Action dated October 24, 2006, applicants submit the following amendments and remarks for entry into the record of the above-identified patent application.

CERTIFICATION OF ELECTRONIC TRANSMISSION

I hereby certify that this document is being filed in the United States Patent and Trademark Office on the date shown below via electronic transmission.

Dated: December 21, 2006

Leslie S. Szivos, Ph.D.